ELECTRON MICROSCOPY

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References:

- "Transmission Electron Microscopy" D.B. Williams and C. B. Carter, 1996, Plenum.
- "Scanning Electron Microscopy and X-ray Microanalysis" J.I. Goldstein, D.E.
- Newbury, P. Echin, D.C. Joy, C.E. Lyman, E. Lifshin, L. Sawyer, and J.R. Michael, 3rd ed, 2003, Kluwer/Plenum.
 - "Diffraction Physics" J.M. Cowley, 3rd ed, 1995, North-Holland.
- "Electron Microscopy of Thin Crystals" P. Hirsch, A. Howie, R.B. Nicholson, D.W. Pashley, and M.J. Whelan; 2nd ed., 1977, Robert E. Krieger.
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- "Procedures in Electron Microscopy", eds. A.W. Robards and A.J. Wilson, 1996 (or later), Wiley.
- "Atlas of Optical Transforms" G. Harburn, C.A. Taylor, and T. R. Welberry; 1967, Cornell University.
 - "DigitalMicrograph", Gatan, Inc.

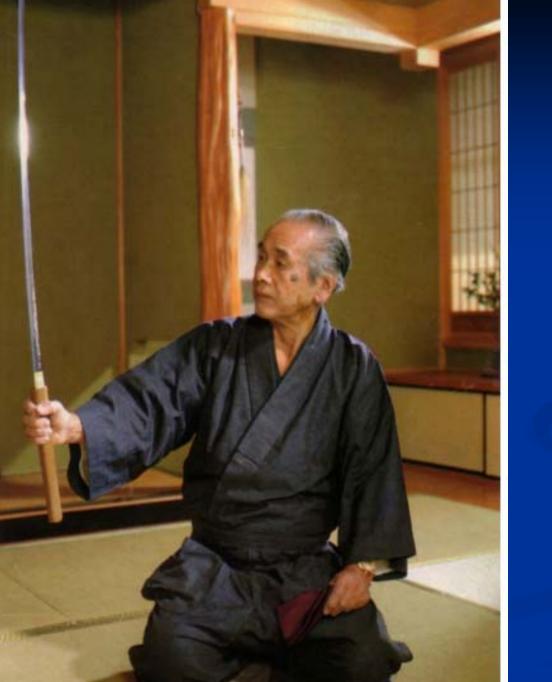
Outline:

Introduction The Electron microscope Principle of image formation Diffraction Specimen preparation Contrast Scanning electron microscopy Electron microprobe / Analytical electron microscopy

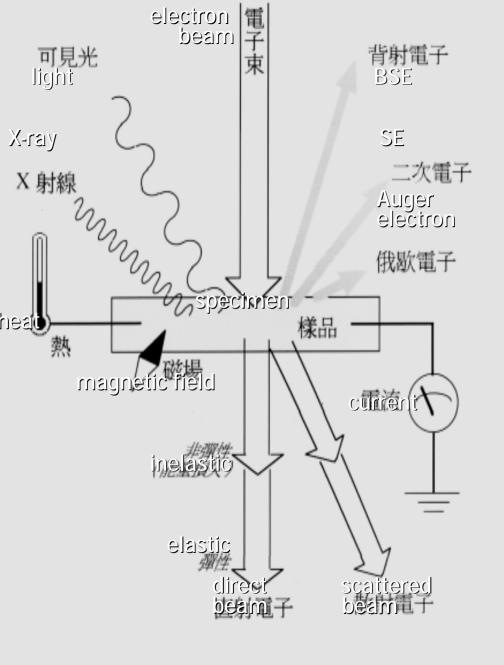
Introduction:

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Why electron microscopy?
  Sensitivity:
    Beam/solid (specimen) interaction
  (Spatial) Resolution:
    Microscopy vs. microprobe
    Wavelength, properties of lens
    Beam/solid interaction
  Information other than the image
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A brief history of electron microscopy



Traditional materials characterization: incidence beam (probe): photon exit beam (signal): photon detector: eye processor/storage: brain (ref. Taiyo)



Beam-solid interaction

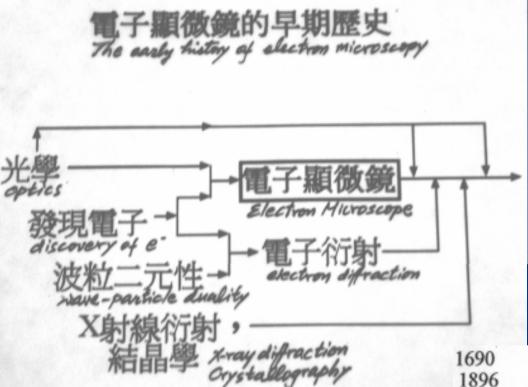
Why electron microscopy?

(Spatial) Resolution:

Microscopy vs. microprobe Wavelength, properties of lens Beam/solid interaction

Information obtainable from electron microscopy Beam/solid interaction image: morphology scattering power crystal structure crystal defects atomic structure

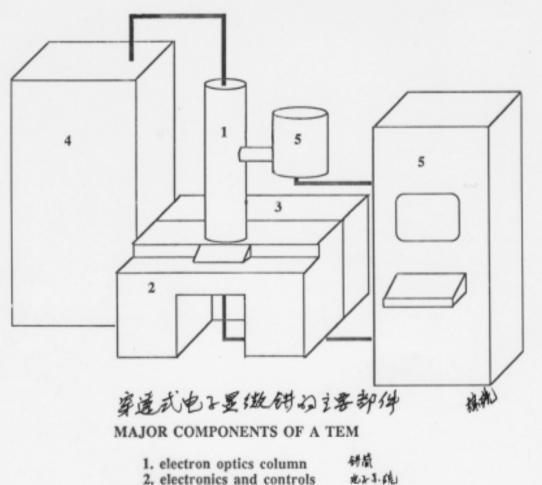
other than the image:
 (chemical) elemental composition
 electronic structure



A brief history of electron microscopy (vg)

Huygens: 光波, 衍射
Röntgen: 發現X射線
Thomson: 發現電子
Bragg and Bragg, von Laue: X射線衍射
de Broglie 波
Schödinger 方程式
Busch: 電子束聚焦
Davisson & Germer, Thomson: 電子衍射
Ruska & Knoll: 鐵心磁鏡
完成電子顯微鏡

Various Electron Microscopes (vg)



3. vacuum system

4. high voltage power supply

5. accessories

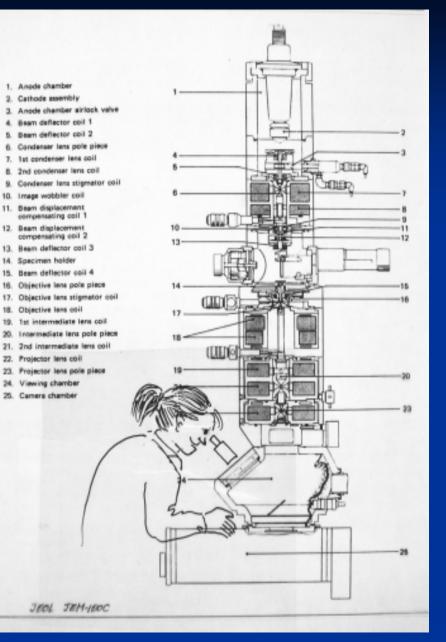
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34件.

The Electron microscope

Structure and major components



The Eelctron Optics Column:

The electron gun:

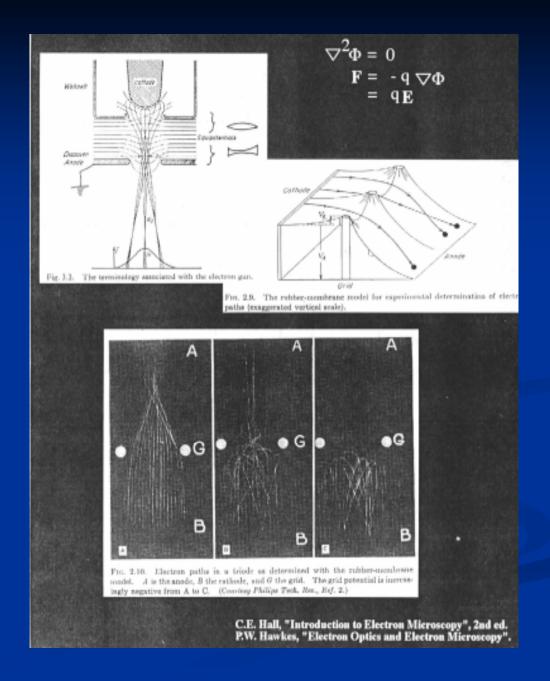
An electrostatic lens + an electron accelerator

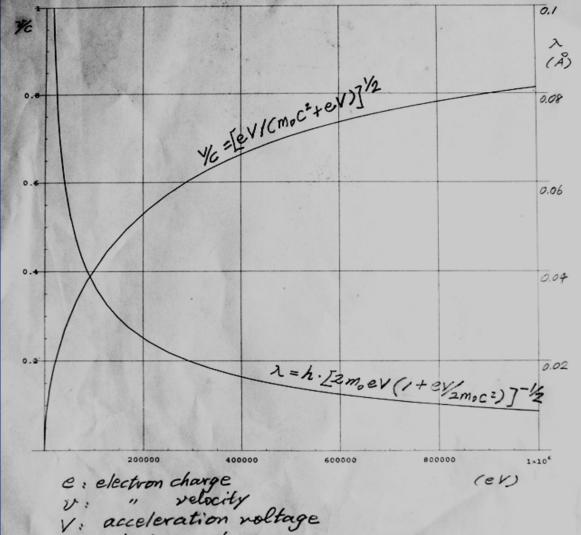
Filament: Tungsten

LaB₆

Field emission

Acceleration voltage: (HV or HT) 100kV – 1MV





Mo: electron rest mass

C: speed of light in vacuum

h: Planck's constant

2: electron wavelength

The electromagnetic lens

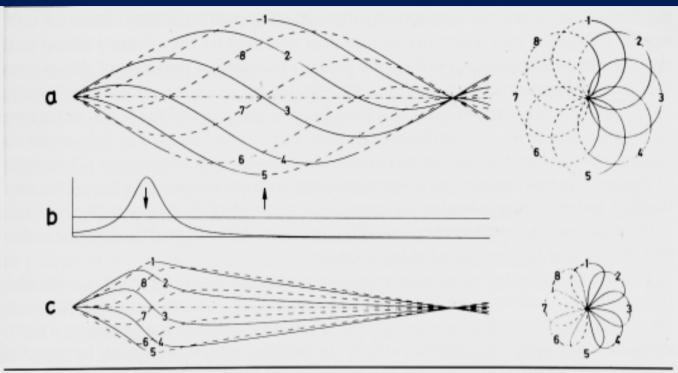


Fig. 1. Electron trajectories in a uniform (a) and in a non-uniform (c) magnetic field, issuing from an axial point of the specimen for different azimuth angles, but making the same angle with the lens axis. (b) Field distributions corresponding to (a) and (c).

"The early development of electron lenses and electron microscopy" Ernst Ruska, 1980, S. Hirzel Verlag Stuttgart

The Lens System:

Condenser Lens:

Control beam intensity, density, convergence, coherence.

Objective Lens:

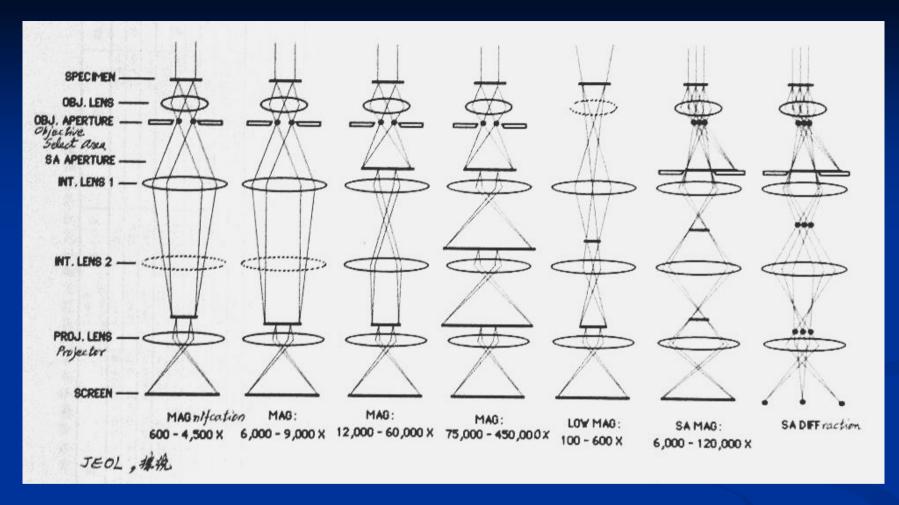
Magnification, introducing contrast.

Intermediate Lens:

Further magnification, imaging or diffraction.

Projector Lens:

Final magnification



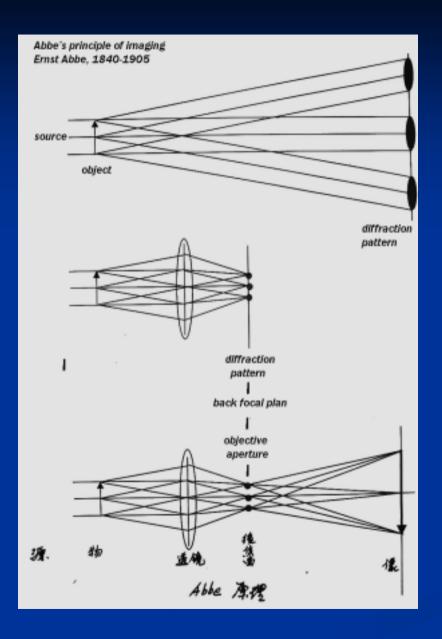
The Electron microscope operation

diffraction pattern

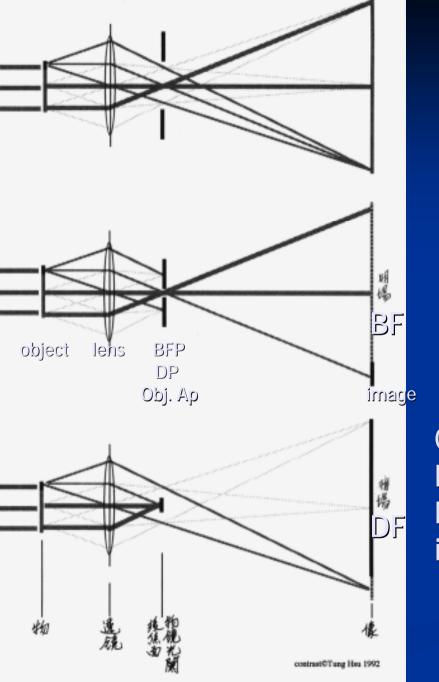
Principle of image formation

Fundamental geometrical and physical optics
Abbe's principle and the back focal plan (BFP)
Contrast: Beam/solid interaction
BFP and the objective aperture:
Bright field (BF) and dark field (DF) images.

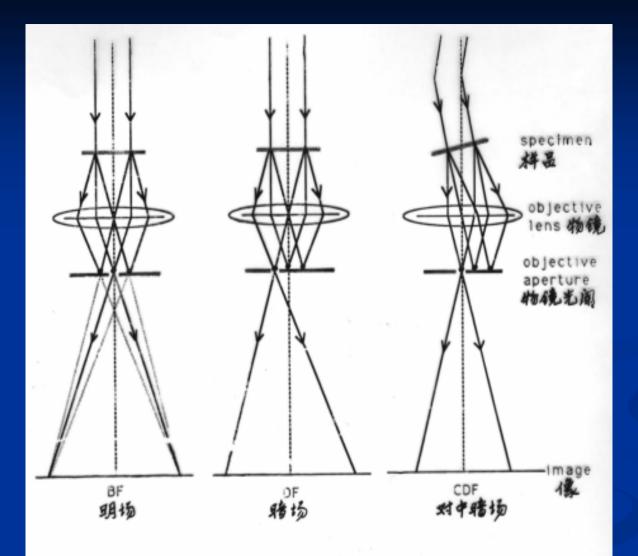
(vg)



Abbe's Principle of Imaging



Contrast: Beam/solid interaction BFP and the objective aperture: Bright field (BF) and dark field (DF) images.



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Diffraction Pattern
Diffraction Contrast

What is Diffraction?

What is DIFFRACTION?

Encyclopadia Britannica 1994-2002

- Diffraction the spreading of waves around obstacles.
- Diffraction takes place with sound; with electromagnetic radiation..., and electrons, which show wavelike properties.
- One consequence of diffraction is that sharp shadows are not
 - produced. The phenomenon is the result of interference...

Wikipedia 2006-2-2

- Diffraction is the bending and spreading of <u>waves</u> when they meet an obstruction. It can occur with any type of wave...
- Diffraction also occurs when any group of waves of a finite size is propagating; for example...
- Diffraction is one particular type of wave <u>interference</u>, caused by the partial obstruction or lateral restriction of a wave; another example...

- Grant R. Fowles, "Introduction to Modern Optics", 2nd ed., 1975, Dover, p. 106
- 5.1. General Description of Diffraction

If an opaque object is placed between a point source of light and a white screen, it is found that the shadow that is cast by the object departs from the perfect sharpness predicted by geometrical optics. Born and Wolf, "Principles of Optics", 4th ed., 1970. Ch. VIII. Elements of the theory of diffraction

In carrying out the transition from the general electromagnetic field to the optical field, which is characterized by very high frequencies (short wavelengths), We found that in certain regions the simple geometrical model of energy propagation was inadequate. In particular, we saw that deviation from this model must be expected in the immediate neighborhood of the boundaries of shadows and in regions where a large number of rays meet. These deviations are manifested by the appearance of dark and bright bands, the diffraction fringes.

Hecht "Optics" 2nd ed, 1989

- p.3. The phenomenon of diffraction, i.e., the deviation from rectilinear propagation that occurs when light advances beyond an obstruction, was first noted ...
- pp. 128-129. ... an optical device is ... unable to collect all the emitted light; the system accepts only a segment of the wavefront... there will always be an apparent deviation from rectilinear propagation even in homogeneous media the wave will be diffracted.

J.M. Cowley, "Diffraction physics"

(No definitions given)

Feynman "Lectures on Physics" Ch. 30. Diffraction

This chapter is a direct continuation of the previous one, although the name has been changed from Interference to Diffraction. No one has ever been able to define the difference between interference and diffraction satisfactorily. It is just a question of usage, and there is no specific, important physical difference between them. The best we can do, roughly speaking, is to say that when there are only a few sources, say two, interfering, then the result is usually called interference, but if there is a large number of them, it seems that the word diffraction is more often used. So, we shall not worry about whether it is interference or diffraction, but continue directly from where we left off in the middle of the subject in the last chapter.

Conclusion:

We don't even need the word "diffraction". What we observe experimentally is the result of wave propagation. When there is an object in the way of the propagating waves, a pattern associated with the shape and nature of the object and the nature of the wave is formed. This can be called the Fresnel pattern or the Fraunhofer pattern, depending upon the approximations used in describing it.

Related terms:

Scattering (of particles)

Reflection (by atom plans in a solid)

WAVE PROPAGATION, SCATTERING, AND SUPERPOSITION

- Electrons fly through the vacuum = electron wave propagating through the vacuum.
- Electrons (electron waves) can be scattered by electrostatic potential of atoms.
- When two or more electron waves meet, their amplitudes are added.

How to add waves:

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Direct method (vg)
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Amplitude-phase diagram (vector method) (vg)

Fourier transform

Optical bench (Atlas) (vg)

Computer (DigitalMicrograph)

Diffraction Patterns from 3D objects

Bragg's Law (vg)
$$n \lambda = 2d \sin \theta$$

Examples of electron micrographs and (transmission) electron diffraction (TED) patterns (vg)

Contrast mechanism:

Beam/specimen interaction

Amplitude and/or phase of the electron waves are altered by the specimen

Properties of lens

Waves (rays) initiated from a point on the object cannot be converged by the lens to a point on the image.

Aperture limitation

Spherical aberration

Chromatic aberration

Defocus

Astigmatism

Detector: Film, CCD

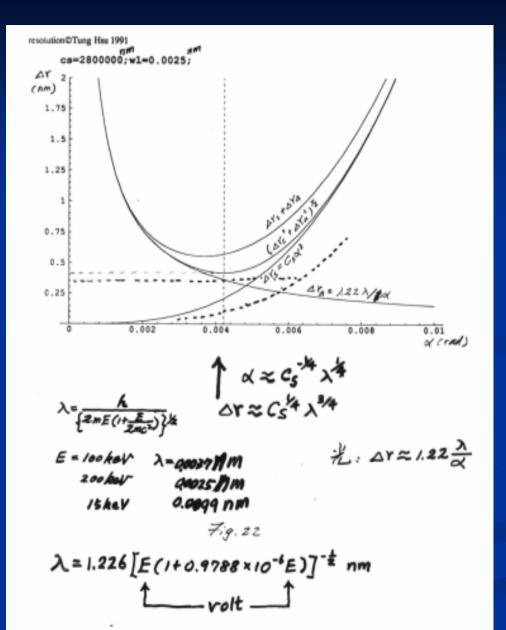
RESOLUTION:

Rayleigh's criterion (vg)

Balancing the spherical aberration effect and the diffraction effect:

Smaller aperture produces larger Airy disc (diffraction pattern of the aperture).

Larger aperture produces more diffused disc due to spherical aberration



Specimen preparation –
Specimen: What characterization is all about.
the ultimate limit of resolution and detectability

General requirements: thin, small, conductive, firm, dry

Various methods
Ultramicrotomy
Mechanical
Chemical
Ion
(Lucky for nano-materials work: Minimal preparation)

Contrast enhancement: Staining, evaporation, decoration

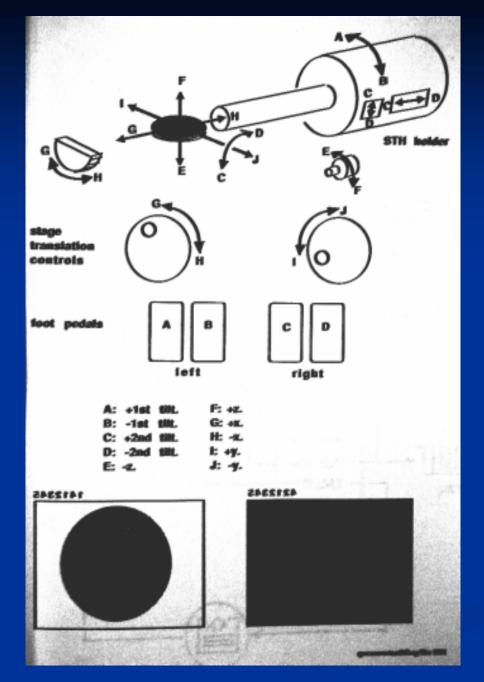
Specimen support and specimen holders

Specimen support: (vg)

Grid Holey carbon grid

Specimen holders: (vg)
Top entry
Side entry
Single/double tilt
Heating, cooling, tensile, environmental, etc.

Performance: Tilt angle, working distance,



Movements and controls of the specimen

High Resolution Electron Microscope (HREM):

Approaching atomic resolution.

Requirements:

(Ultra) high resolution pole piece

Electronic stability

Mechanical stability

Clean environment: (Ultra) high vacuum

Specimen preparation: very very thin

In general HREM is needed for studying nano-materials.

Scanning electron microscopy – microprobe

Beam/specimen interaction: When the specimen is thick, "semi-infinite".

Monte Carlo simulation

The probe forming system: (vg)

Forming a small probe is the same as forming a small spot in the image

The column

Contrast mechanism:

Secondary electrons Back scattered electrons Other signals

Resolution:

Low mag: limited by scan rate High mag: limited by lens defects – same as TEM

Detector

Introduction

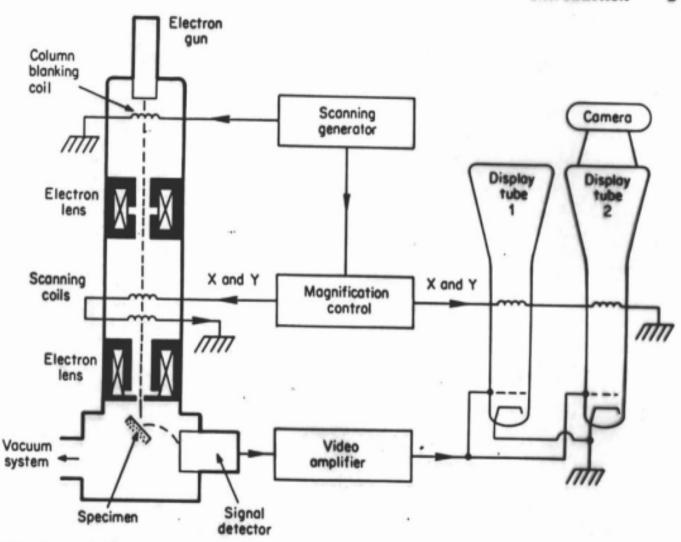
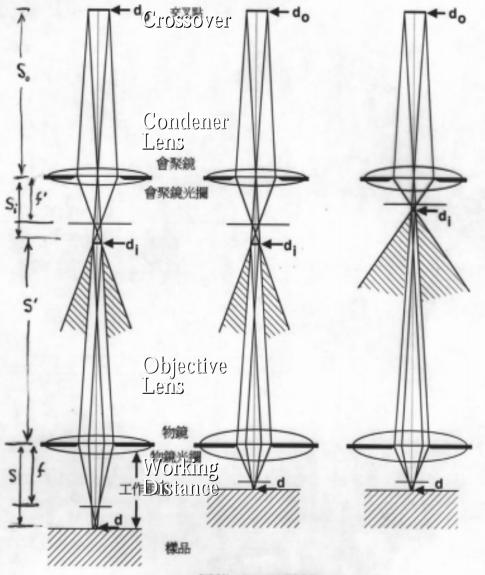


FIG. 1.2 Scanning electron microscope.

40.0



Probe forming in SEM

sem©Tung Hsu, 199

Ref. "Scanning electron microscopy and x-ray microanlalysis", Goldstein, et al, 1981, Plenum, Ch. 2.

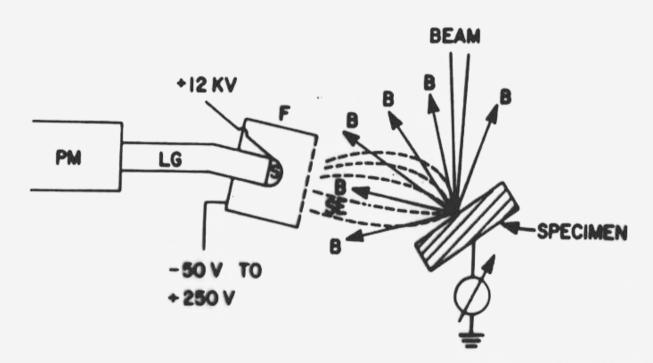
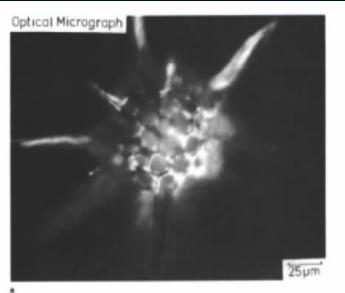


Figure 4.17. Schematic diagram of Everhart-Thornley scintillator-photomultiplier electron detector. B, backscattered electron; SE, secondary electron; F, Faraday cage; S, scintillator; LG, light guide; PM, photomultiplier.



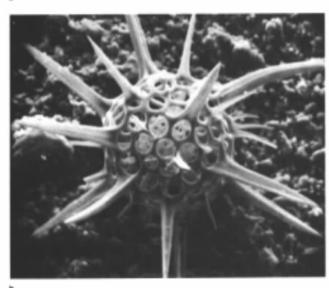
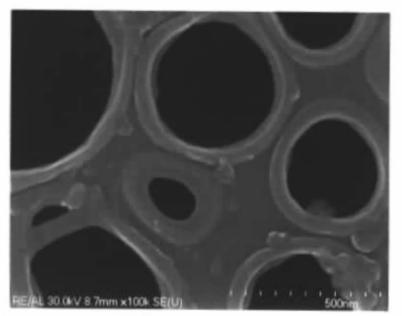
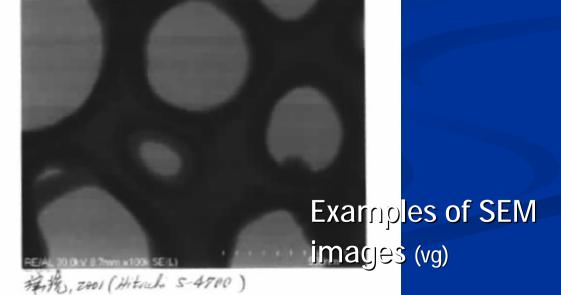


Figure 1.3. (a) Optical micrograph of the risholarian Tricholarian (oxigisposis) (b) SEM micrograph of same radiolarian. The greates depth of focus and superior resolving capability of the SEM are apparent.





Resolution: beam size

$$r = \lambda^{3/4} C s^{1/4}$$

image point size

$$r = \lambda^{3/4} C s^{1/4}$$

Electron microprobe / Analytical electron microscopy:

Energy dispersive (X-ray) spectrometer, EDS (EDX)
Wavelength dispersive (X-ray) spectrometer, WDS (WDX)
Electron energy loss spectroscopy, EELS
Quantitative analysis
etc.

	Со	Ni	Те	1
Mendeleev:	A = 58.9	58.6	127.7	126.9
Moseley:	Z = 27	28	52	53

Parameter	nλ	2d	sine
diffraction	known	calculated	measured
spectrometry(WDS)	calculated	known	measured
spectrometry(EDS)	E: measured	100 1000	111146650

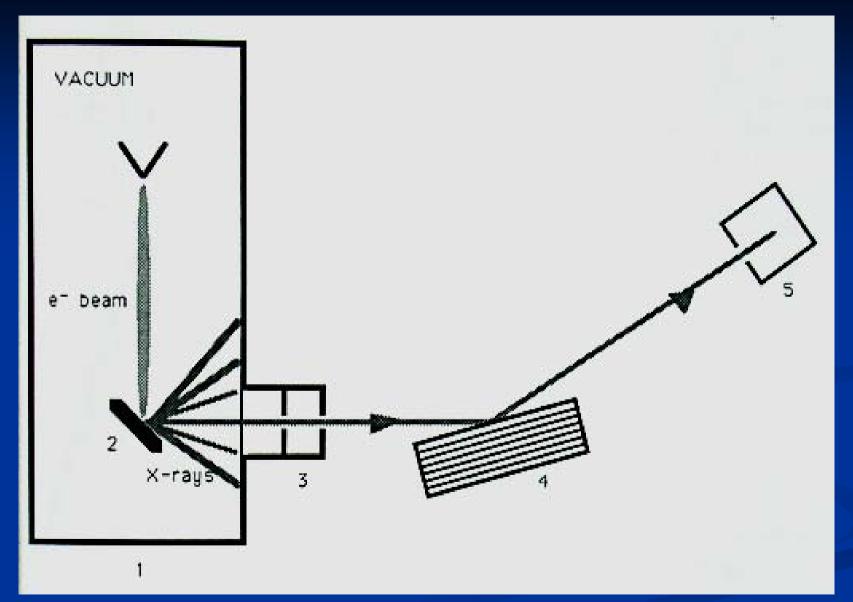
E=hc/
$$\lambda$$
, λ = C'(Z - σ)-2 (for the same spectral line, K \propto , K β , ...)

Instrumentation: Electron probe/microscope Other particle beam x-ray fluorescence radioactive sources

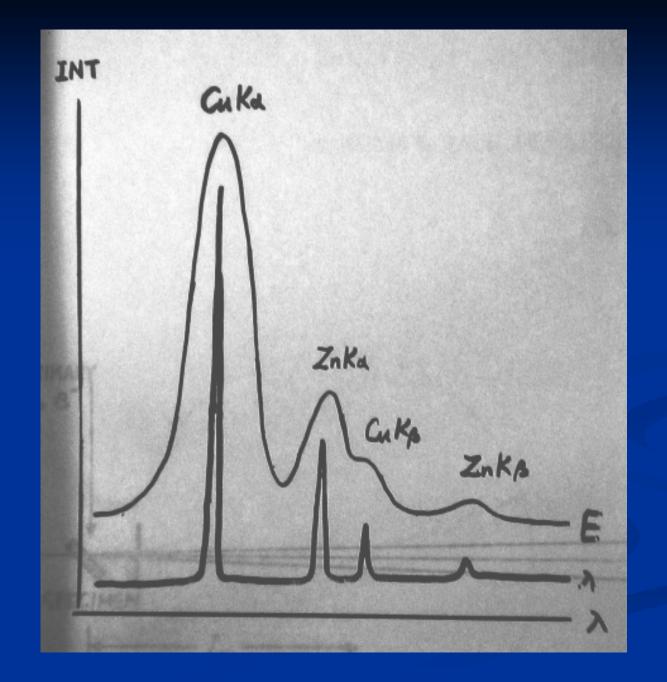
WDS: X-ray optics regular crystals ⇒ O and up "soap" film crystals ⇒ Be and up

EDS: Si(Li) detector
Multi-channel analyzer (MCA)
Be window ⇒ Na and up

Ultra-thin window or Windowless ⇒ B and up Dead layer in Si(Li) detector is the limit



XRD and WDS



Microscopy Society of America Position on Ethical Digital Imaging

RESOLUTION carried as follows: Be it resolved that the MSA position on digital image processing be approved as follows:

"Ethical digital imaging requires that the original uncompressed image file be stored on archival media (e.g., CD-R) without any image manipulation or processing operation. All parameters of the production and acquisition of this file, as well as any subsequent processing steps, must be documented and reported to ensure reproducibility.

Generally, acceptable (non-reportable) imaging operations include gamma correction, histogram stretching, and brightness and contrast adjustments. All other operations (such as Unsharp-Masking, Gaussian Blur, etc.) must be directly identified by the author as part of the experimental methodology. However, for diffraction data or any other image data that is used for subsequent quantification, all imaging operations must be reported."

MSA 2003 Summer Council Meeting Minutes